IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Andriessen

Art Unit: Unassigned

Application No. Unassigned

Examiner: Unassigned

Filed: July 29, 2003

For: NANO-POROUS METAL OXIDE SEMICONDUCTOR

SPECTRALLY SENSITIZED WITH METAL OXIDE

CHALCOGENIDE NANO-PARTICLES

CLAIM OF PRIORITY

Mail Stop Patent Application Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 35 USC 119, Applicant claims the priority of the following application:

Application No. 02102129.0, filed in Europe on August 13, 2002.

A certified copy of the above-listed priority document is enclosed.

Respectfully submitted,

Christopher T. Griffith, Reg. No. 33,392 LEYDIG, VOIT & MAYER, LTD. Two Prudential Plaza, Suite 4900

180 North Stetson

Chicago, Illinois 60601-6780 Telephone: (312) 616-5600 Facsimile: (312) 616-5700

Date: July 29, 2003

| • | | | |
|---|------|---|--|
| | | | |
| | • | | |
| | | | |
| | ¥. | | |
| | | • | |
| · | | | |
| | | | |
| | | | |
| | ¥F : | | |
| | | | |
| | | | |
| | | | |



Europäisch s **Patentamt**

European **Patent Office** Offic eur pé n des br vets

Bescheinigung

Certificate

Attestation

Die angehefteten Unterlagen stimmen mit der ursprünglich eingereichten Fassung der auf dem nächsten Blatt bezeichneten europäischen Patentanmeldung überein.

The attached documents are exact copies of the European patent application conformes à la version described on the following page, as originally filed.

Les documents fixés à cette attestation sont initialement déposée de la demande de brevet européen spécifiée à la page suivante.

Patentanmeldung Nr.

Patent application No. Demande de brevet n°

02102129.0

Der Präsident des Europäischen Patentamts; Im Auftrag

For the President of the European Patent Office

Le Président de l'Office européen des brevets p.o.

R C van Dijk

Ĵ

•

.

1



Anmeldung Nr:

Application no.: 02102129.0

Demande no:

Anmeldetag:

Date of filing: 13.08.02

Date de dépôt:

Anmelder/Applicant(s)/Demandeur(s):

AGFA-GEVAERT Septestraat 27 2640 Mortsel BELGIQUE

Bezeichnung der Erfindung/Title of the invention/Titre de l'invention: (Falls die Bezeichnung der Erfindung nicht angegeben ist, siehe Beschreibung. If no title is shown please refer to the description. Si aucun titre n'est indiqué se referer à la description.)

Nano-porous metal oxide semiconductor spectrally sensitized with metal chalcogenide nano-particles

In Anspruch genommene Prioriät(en) / Priority(ies) claimed /Priorité(s) revendiquée(s)
Staat/Tag/Aktenzeichen/State/Date/File no./Pays/Date/Numéro de dépôt:

Internationale Patentklassifikation/International Patent Classification/Classification internationale des brevets:

H01L21/00

Am Anmeldetag benannte Vertragstaaten/Contracting states designated at date of filing/Etats contractants désignées lors du dépôt:

AT BE BG CH CY CZ DE DK EE ES FI FR GB GR IE IT LI LU MC NL PT SE SK TR

. ÿ. · *

DESCRIPTION

Field of the invention

5 The present invention relates to a nano-porous metal oxide semiconductor in-situ spectrally sensitized with a metal chalcogenide.

Background of the invention.

10

There are two basic types of photoelectrochemical photovoltaic The first type is the regenerative cell which converts light to electrical power leaving no net chemical change behind. Photons of energy exceeding that of the band gap generate electron-15 hole pairs, which are separated by the electrical field present in the space-charge layer. The negative charge carriers move through the bulk of the semiconductor to the current collector and the external circuit. The positive holes (h⁺) are driven to the surface where they are scavenged by the reduced form of the redox 20 relay molecular (R), oxidizing it: $h^+ + R \rightarrow 0$, the oxidized form. O is reduced back to R by the electrons that re-enter the cell from the external circuit. In the second type, photosynthetic cells, operate on a similar principle except that there are two redox systems: one reacting with the holes at the surface of the 25 semiconductor electrode and the second reacting with the electrons entering the counter-electrode. In such cells water is typically oxidized to oxygen at the semiconductor photoanode and reduced to hydrogen at the cathode. Titanium dioxide has been the favoured semiconductor for these studies. Unfortunately because of its 30 large band-gap (3 to 3.2 eV), TiO2 absorbs only part of the solar emission and so has low conversion efficiencies. Graetzel reported in 2001 in Nature, volume 414, page 338, that numerous attempts to shift the spectral response of TiO2 into the visible had so far failed.

35 Mesoscopic or nano-porous semiconductor materials, minutely structured materials with an enormous internal surface area, have been developed for the first type of cell to improve the light capturing efficiency by increasing the area upon which the spectrally sensitizing species could adsorb. Arrays of nano40 crystals of oxides such as TiO₂, ZnO, SnO₂ and Nb₂O₅ or chalcogenides such as CdSe are the preferred semiconductor materials and are interconnected to allow electrical conduction to take place. A wet

type solar cell having a porous film of dye-sensitized titanium dioxide semiconductor particles as a work electrode was expected to surpass an amorphous silicon solar cell in conversion efficiency and cost. These fundamental techniques were disclosed in 1991 by Graetzel et al. in Nature, volume 353, pages 737-740 and in US 4,927,721, US 5,350,644 and JP-A 05-504023. Graetzel et al. reported solid-state dye-sensitized mesoporous TiO₂ solar cells with up to 33% photon to electron conversion efficiences.

In 1995 Tennakone et al. in Semiconductor Sci. Technol.,

volume 10, page 1689 and O'Regan et al. in Chem. Mater., volume 7,

page 1349 reported an all-solid-state solar cell consisting of a

highly structured hetero-junction between a p- and n-type

semiconductor with a absorber in between in which the p
semiconductor is CuSCN or CuI, the n-semiconductor is nano-porous

titanium dioxide and the absorber is an organic dye.

Furthermore, in 1998 K. Tennakone et al. reported in Journal Physics A: Applied Physics, volume 31, pages 2326-2330, a nanoporous n-TiO₂/~23 nm selenium film/p-CuCNS photovoltaic cell which generated a photocurrent of ~3.0 mA/cm², a photovoltage of ~600 mV at 800 W/m² simulated sunlight and a maximum energy conversion efficiency of ~0.13%.

Vogel et al. in 1990 in Chemical Physics Letters, volume 174, page 241, reported the sensitization of highly porous TiO2 with insitu prepared quantum size CdS particles (40-200Å), a photovoltage 25 of 400 mV being achieved with visible light and high photon to current efficiences of greater than 70% being achieved at 400 nm and an energy conversion efficiency of 6.0% under monochromatic illumination with $\lambda = 460$ nm. In 1994 Hoyer et al. reported in Applied Physics, volume 66, page 349, that the inner surface of a 30 porous titanium dioxide film could be homogeneously covered with isolated quantum dots and Vogel et al. reported in Journal of Physical Chemistry, volume 98, pages 3183-3188, the sensitization of various nanoporous wide-bandgap semiconductors, specifically TiO2, Nb2O5, Ta2O5, SnO2 and ZnO, with quantum-sized PbS, CdS, Ag2S, 35 Sb₂S₃ and Bi₂S₃ and the use of quantum dot-sensitzed oxide semiconductors in liquid junction cells. The internal photocurrent quantum yield decreased with increasing particle diameter and decreased in the order $TiO_2 > ZnO > Nb_2O_5 > SnO_2 > Ta_2O_5$.

EP-A 1 176 646 discloses a solid state p-n heterojunction of comprising an electron conductor and a hole conductor, characterized in that if further comprises a sensitizing semiconductor, said sensitizing being located at an interface

between said electron conductor and said hole conductor; and its application in a solid state sensitized photovolaic cell. preferred embodiment the sensitizing semiconductor is in the form of particles adsorbed at the surface of said electron conductor and 5 in a further preferred embodiment the sensitizing semiconductor is in the form of quantum dots, which according to a particularly preferred embodiment are particles consisting of PbS, CdS, Bi₂S₃, Sb₂S₃, Ag₂S, InAs, CdTe, CdSe or HgTe or solid solutions of HgTe/CdTe or HgSe/CdSe. In another preferred embodiment the 10 electron conductor is a ceramic made of finely divided large band gap metal oxide, with nanocrystalline TiO2 being particularly preferred. EP-A 1 176 646 further includes an example for making a layered heterojunction in which SnO2-coated glass was coated with a compact TiO2 layer by spray pyrolysis, PbS quantum dots were 15 deposited upon the TiO2 layer, the hole conductor 2,2',7,7'tetrakis (N, N-di-p-methoxyphenyl-amine) 9,9'-spirobifluorene (OMeTAD) was deposited on the quantum dots and a semitransparent gold back contact was evaporated on the OMeTAD layer.

There is a need for nano-particles with improved stability for spectrally sensitizing nano-porous metal oxide semiconductor layers.

Aspects of the invention.

It is therefore an aspect of the present invention to provide improved spectral sensitization of nano-porous metal oxide semiconductors.

It is a further aspect of the present invention to provide a process for realizing improved spectral sensitization of nano30 porous metal oxide semiconductors.

Further aspects and advantages of the invention will become apparent from the description hereinafter.

Summary of the invention.

35

It has been surprisingly found that spectral sensitization of nano-porous metal oxides on their internal and external surfaces with metal chalcogenide nano-particles is enhanced by the presence of a triazole or diazole compound.

Aspects of the present invention are realized by a nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV in-situ spectrally sensitized on its internal and external surface

with metal chalcogenide nano-particles with a band-gap of less than 2.9 eV containing at least one metal chalcogenide, characterized in that the nano-porous metal oxide semiconductor further contains a triazole or diazole compound.

Aspects of the present invention are also realized by a process for in-situ spectral sensitization of nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV on its internal and external surface with metal chalcogenide nano-particles with a band-gap of less than 2.9 eV, containing at least one metal chalcogenide, comprising a metal chalcogenide-forming cycle comprising the steps of: contacting the nano-porous metal oxide with a solution of metal ions; and contacting the nano-porous metal oxide with a solution of chalcogenide ions, wherein the solution of metal ions and/or the solution of chalcogenide ions tontains a triazole or diazole compound.

Aspects of the present invention are also realized by a photovoltaic device comprising the above-mentioned nano-porous metal oxide in-situ spectrally sensitized on its internal and external surface with metal chalcogenide nano-particles.

Preferred embodiments are disclosed in the dependent claims.

Detailed description of the invention.

Figure 1 represents the dependence of absorbance [A] upon
25 wavelength [λ] in nm for: a, unsensitized nano-porous TiO₂ layer (. absorbance at 500 nm = 0.15); b, nano-porous TiO₂ layer sensitized with PbS with one dipping cycle (absorbance at 500 nm = 0.26); c, nano-porous TiO₂ layer sensitized with Bi₂S₃ with one dipping cycle (absorbance at 500 nm = 0.28); d, nano-porous TiO₂ layer
30 sensitized with PbS with three dipping cycles (absorbance at 500 nm = 0.65); and e, nano-porous TiO₂ layer sensitized with Bi₂S₃ with three dipping cycles (absorbance at 500 nm = 2.50).

Definitions

35

20

The term nano-porous metal oxide semiconductor means a metal oxide semiconductor having pores with a size of 100 nm or less and having an internal surface area of at least 20 $\rm m^2/g$ and not more than 300 $\rm m^2/g$.

The term chalcogenide means a binary compound containing a chalcogen and a more electropositive element or radical. A

chalcogen is an element from group IV of the periodic table including oxygen, sulphur, selenium, tellurium and polonium.

The term "a mixture of two or more metal chalcogenides" includes a simple mixture thereof, mixed crystals thereof and doping of a metal chalcogenide by metal or chalcogenide replacement.

The term internal surface means the surface of pores inside a porous material.

The term in-situ spectrally sensitized means that the spectral 10 sensitizer is formed where spectral sensitization is required.

The term aqueous for the purposes of the present invention means containing at least 60% by volume of water, preferably at least 80% by volume of water, and optionally containing water-miscible organic solvents such as alcohols e.g. methanol, ethanol, 2-propanol, butanol, iso-amyl alcohol, octanol, cetyl alcohol etc.; glycols e.g. ethylene glycol; glycerine; N-methyl pyrrolidone; methoxypropanol; and ketones e.g. 2-propanone and 2-butanone etc.

The term "support" means a "self-supporting material" so as to distinguish it from a "layer" which may be coated on a support, but 20 which is itself not self-supporting. It also includes any treatment necessary for, or layer applied to aid, adhesion to the support.

The term continuous layer refers to a layer in a single plane covering the whole area of the support and not necessarily in direct contact with the support.

The term non-continuous layer refers to a layer in a single plane not covering the whole area of the support and not necessarily in direct contact with the support.

The term coating is used as a generic term including all means of applying a layer including all techniques for producing continuous layers, such as curtain coating, doctor-blade coating etc., and all techniques for producing non-continuous layers such as screen printing, ink jet printing, flexographic printing, and techniques for producing continuous layers.

The abbreviation PEDOT represents poly(3,4-ethylenedioxy-thiophene).

The abbreviation PSS represents poly(styrene sulphonic acid) or poly(styrenesulphonate).

Nano-porous metal oxide semiconductor

Aspects of the present invention are realized by a nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV 5 in-situ spectrally sensitized on its internal and external surface with metal chalcogenide nano-particles with a band-gap of less than 2.9 eV containing at least one metal chalcogenide, characterized in that the nano-porous metal oxide further contains a triazole or diazole compound.

According to a first embodiment of the nano-porous metal oxide semiconductor, according to the present invention, the metal oxide semiconductor is n-type.

According to a second embodiment of the nano-porous metal oxide, according to the present invention, the metal oxide is selected from the group consisting of titanium oxides, tin oxides, niobium oxides, tantalum oxides, tungsten oxides and zinc oxides.

According to a third embodiment of the nano-porous metal oxide semiconductor, according to the present invention, the nano-porous metal oxide semiconductor is titanium dioxide.

20

Metal chalcogenide

Aspects of the present invention are realized by a nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV 25 in-situ spectrally sensitized on its internal and external surface with metal chalcogenide nano-particles with a band-gap of less than 2.9 eV containing at least one metal chalcogenide, characterized in that the nano-porous metal oxide further contains a triazole or diazole compound.

According to a fourth embodiment of the nano-porous metal oxide, according to the present invention, the metal chalcogenide is a metal oxide, metal sulphide, metal selenide or a mixture of two or more thereof.

According to a fifth embodiment of the nano-porous metal oxide, 35 according to the present invention, the metal chalcogenide is a metal sulphide or a mixture of two or more thereof.

According to a sixth embodiment of the nano-porous metal oxide, according to the present invention, the metal chalcogenide is selected from the group consisting of lead sulphide, bismuth 40 sulphide, cadmium sulphide, silver sulphide, antimony sulphide, indium sulphide, copper sulphide, cadmium selenide, copper

selenide, indium selenide, cadmium telluride or a mixture of two or more thereof.

Triazole or diazole compound

5

Aspects of the present invention are realized by a nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV in-situ spectrally sensitized on its internal and external surface with metal chalcogenide nano-particles with a band-gap of less than 10 2.9 eV containing at least one metal chalcogenide.

According to a seventh embodiment of the nano-porous metal oxide, according to the present invention, the triazole compound is a tetraazaindene.

According to an eighth embodiment of the nano-porous metal 15 oxide, according to the present invention, the triazole compound is selected from the group consisting of

$$\begin{array}{c|c} & OH & OH & OH \\ \hline & N & N & OH \\ \hline & OH & N & OH \\ \hline & N & N & OH \\ \hline & N & N & OH \\ \hline \end{array}$$
 and

20 Suitable triazole or diazole compounds, according to the present invention, include:

| T1 | H ₃ C N N | 5-methyl-1,2,4- triazolo-(1,5- a)-pyrimidine- 7-ol |
|----|----------------------|---|
| Т2 | HO N N N | |

Phosphoric acid or phosphate

According to a ninth embodiment of the nano-porous metal oxide, s according to the present invention, the nano-porous metal oxide further contains a phosphoric acid or a phosphate.

According to a tenth embodiment of the nano-porous metal oxide, according to the present invention, the phosphoric acid is selected from the group consisting of, orthophosphoric acid, phosphorous acid, hypophosphorous acid and polyphosphoric acids.

Polyphosphoric acids include diphosphoric acid, pyrophosphoric acid, triphosphoric acid, tetraphosphoric acid, metaphosphoric acid and "polyphosphoric acid".

According to an eleventh embodiment of the nano-porous metal 15 oxide, according to the present invention, the phosphate is -- -- selected from the group consisting of orthophosphates, phosphites, hypophosphites and polyphosphates.

Polyphosphates are linear polyphosphates, cyclic polyphosphates or mixtures thereof. Linear polyphosphates contain 20 2 to 15 phosphorus atoms and include pyrophosphates, dipolyphosphates, tripolyphosphates and tetrapolyphosphates. Cyclic polyphosphates contain 3 to 8 phosphorus atoms and include trimetaphosphates and tetrametaphosphates and metaphosphates.

Polyphosphoric acid may be prepared by heating H_3PO_4 with sufficient P_4O_{10} (phosphoric anhydride) or by heating H_3PO_4 to remove water. A P_4O_{10}/H_2O mixture containing 72.74% P_4O_{10} corresponds to pure H_3PO_4 , but the usual commercial grades of the acid contain more water. As the P_4O_{10} content $H_4P_2O_7$, pyrophosphoric acid, forms along with P_3 through P_8 polyphosphoric acids. Triphosphoric acid appears at 71.7% P_2O_5 ($H_5P_3O_{10}$) and tetraphosphoric acid ($H_6P_4O_{13}$) at about 75.5% P_2O_5 . Such linear

35

polyphosphoric acids have 2 to 15 phosphorus atoms, which each bear a strongly acidic OH group. In addition, the two terminal P atoms are each bonded to a weakly acidic OH group. Cyclic polyphosphoric acids or metaphosphoric acids, $H_n P_n O_{3n}$, which are formed from low-some molecular polyphosphoric acids by ring closure, have a comparatively small number of ring atoms (n=3-8). Each atom in the ring is bound to one strongly acidic OH group. High linear and cyclic polyphosphoric acids are present only at acid concentrations above 82% P_2O_5 . Commercial phosphoric acid has a 82 to 85% by weight P_2O_5 content. It consists of about 55% tripolyphosphoric acid, the remainder being H_3PO_4 and other polyphosphoric acids.

A polyphosphoric acid suitable for use according to the present invention is a 84% (as P_2O_5) polyphosphoric acid supplied by ACROS (Cat. No. 19695-0025).

process for in-situ spectral sensitization of nano-porous metal oxide with metal chalcogenide nano-particles

Aspects of the present invention are also realized by a process for in-situ spectral sensitization of nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV on its internal and external surface with metal chalcogenide nano-particles with a band-gap of less than 2.9 eV, containing at least one metal chalcogenide, comprising a metal chalcogenide-forming cycle comprising the steps of: contacting nano-porous metal oxide with a solution of metal ions; and contacting nano-porous metal oxide with a solution of chalcogenide ions, wherein the solution of metal ions and/or the solution of chalcogenide ions contains a triazole or diazole compound.

According to a first embodiment of the process, according to the present invention, the contact with a solution of metal ions occurs before the contact with a solution of chalcogenide ions.

According to a second embodiment of the process, according to the present invention, the metal chalcogenide is repeated.

According to a third embodiment of the process, according to the present invention, the triazole or diazole compound is tetraazaindene is 5-methyl-1,2,4-triazolo-(1,5-a)-pyrimidine-7-ol.

According to a fourth embodiment of the process, according to the present invention, at the end of the metal chalcogenide-forming cycle the metal chalcogenide is rinsed with an aqueous solution containing a phosphoric acid or a phosphate.

10

Support

Supports for use according to the present invention include polymeric films, silicon, ceramics, oxides, glass, polymeric film reinforced glass, glass/plastic laminates, metal/plastic laminates, paper and laminated paper, optionally treated, provided with a subbing layer or other adhesion promoting means to aid adhesion to adjacent layers. Suitable polymeric films are poly(ethylene terephthalate), poly(ethylene naphthalate), polystyrene, polyethersulphone, polycarbonate, polyacrylate, polyamide, polyimides, cellulosetriacetate, polyolefins and poly(vinylchloride), optionally treated by corona discharge or glow discharge or provided with a subbing layer.

Photovoltaic devices

Aspects of the present invention are also realized by a photovoltaic device comprising the layer configuration, according to the present invention, or produced according to the process, according to the present invention.

Photovoltaic devices incorporating the spectrally sensitized nano-porous metal oxide, according to the present invention, can be of two types: the regenerative type which converts light into electrical power leaving no net chemical change behind in which 25 current-carrying electrons are transported to the anode and the external circuit and the holes are transported to the cathode where they are oxidized by the electrons from the external circuit and the photosynthetic type in which there are two redox systems one reacting with the holes at the surface of the semiconductor 30 electrode and one reacting with the electrons entering the counterelectrode, for example, water is oxidized to oxygen at the semiconductor photoanode and reduced to hydrogen at the cathode. In the case of the regenerative type of photovoltaic cell, as exemplified by the Graetzel cell, the hole transporting medium may 35 be a liquid electrolyte supporting a redox reaction, a gel electrolyte supporting a redox reaction, an organic hole transporting material, which may be a low molecular weight material such as 2,2',7,7'-tetrakis(N,N-di-p-methoxyphenyl-amine)9,9'spirobifluorene (OMeTAD) or triphenylamine compounds or a polymer 40 such as PPV-derivatives, poly(N-vinylcarbazole) etc., or inorganic semiconductors such as CuI, CuSCN etc. The charge transporting process can be ionic as in the case of a liquid electrolyte or gel

35

electrolyte or electronic as in the case of organic or inorganic hole transporting materials.

Such regenerative photovoltaic devices can have a variety of internal structures in conformity with the end use. Conceivable forms are roughly divided into two types: structures which receive light from both sides and those which receive light from one side. An example of the former is a structure made up of a transparently conductive layer e.g. an ITO-layer or a PEDOT/PSS-containing layer and a transparent counter electrode electrically conductive layer e.g. an ITO-layer or a PEDOT/PSS-containing layer having interposed therebetween a photosensitive layer and a charge transporting layer. Such devices preferably have their sides sealed with a polymer, an adhesive or other means to prevent deterioration or volatilization of the inside substances. The external circuit connected to the electrically-conductive substrate and the counter electrode via the respective leads is well-known.

Alternatively the spectrally sensitized nano-porous metal oxide, according to the present invention, can be incorporated in hybrid photovoltaic compositions such as described in 1991 by 20 Graetzel et al. in Nature, volume 353, pages 737-740, in 1998 by U. Bach et al. [see Nature, volume 395, pages 583-585 (1998)] and in 2002 by W. U. Huynh et al. [see Science, volume 295, pages 2425-2427 (2002)]. In all these cases, at least one of the components (light absorber, electron transporter or hole transporter) is inorganic (e.g. nano-TiO2 as electron transporter, CdSe as light absorber and electron transporter) and at least one of the components is organic (e.g. triphenylamine as hole transporter or poly(3-hexylthiophene) as hole transporter).

Industrial application

Spectrally sensitized nano-porous metal oxide, according to the present invention, can be used in a both regenerative and photosynthetic photovoltaic devices.

The invention is illustrated hereinafter by way of reference and invention photovoltaic devices. The percentages and ratios given in these examples are by weight unless otherwise indicated.

. 25

12

EXAMPLE 1

Preparation of solutions used in in-situ preparation of nanosulphide particles

Metal solution 1:

Metal solution 1, a 0.6 M Bi $^{3+}$ -solution, was prepared by mixing 36 mL of deionized water, 6.2 mL of concentrated HNO $_3$ and 28.75 g of 10 Bi(NO $_3$) $_3$.5H $_2$ O, then adding a solution of 40 g triammonium citrate in 36 mL of deionized water and finally slowly adding 16 mL of a 50% NaOH-solution.

Metal solution 2:

Metal solution 2, a 0.96 M Pb^{2+} -solution, was prepared by dissolving 37.65 g of $Pb(NO_3)_2$ in 100 mL of deionized water.

Sulphide solution 1:

Sulphide solution 1, a 0.1 M S^{2-} solution, was prepared by dissolving 0.78 g of Na₂S in 100 mL of deionized water.

Efficient adsorption of nano-sulphides on a nano-porous ${\tt TiO_2}$ layer.

A glass substrate (FLACHGLAS AG) was ultrasonically cleaned in ethanol for 5 minutes and then dried. A layer of a nano-TiO2 dispersion (Ti-nanoxide HT Solaronix SA) was applied to the glass substrate using a doctor blade coater. This titanium dioxide-coated 30 glass was heated to 450°C for 30 minutes. This results in a highly transparent nano-porous TiO₂ layer. A dry layer thickness of 1.4 μm was obtained as verified by laserprofilometry (DEKTRAK™ profilometer), mechanically with a diamond-tipped probe (Perthometer) and interferometry.

After the sintering step, the titanium dioxide-coated glass plates were cooled to 150°C by placing them on a hot plate at 150°C for 10 minutes and then immediately dipped into the metal solution for 1 minute, then rinsed for 10 seconds with deionized water immediately followed by dipping for 1 minute in the sulphide solution and finally rinsing once more with deionized water for 10 seconds. In this dipping cycle nano-metal sulphides were deposited on the internal and external surface of the nano-porous titanium

dioxide. The amount of adsorbed nano-metal sulphide particles could be increased by carrying out multiple dipping cycles.

Absorption spectra between 200 and 800 nm were obtained using a Hewlett-Packard diode-array spectrophotometer HP 8452A. Figure 1 5 shows the absorption spectra for pure TiO2, TiO2 with one cycle of Metal solution 1 (Bi³⁺) and Sulphide solution 1; and TiO₂ with one cycle of Metal solution 2 (Pb2+) and Sulphide solution 1. The absorption band is very broad and as a point of reference only the absorbance values at 500 nm will be given in the examples below.

Dipping cycles were carried out with Metal solutions 1 and 2 and Sulphide solution 1; and with the triazole compounds T1, T2 and T3 added to Metal solution 1, Metal solution 2 or to Sulphide solution 1 (7,5 ml of 10% solution of the triazole compound) in water was added to 50 ml of the metal or sulphide solution) as 15 given in Table 1 and the absorbances at 500 nm of the resulting insitu formed nano-metal sulphides determined, see Table 1.

Multiple dipping led to higher absorbances. The presence of a triazole in either the Metal solution or the Sulphide solution resulted in a more rapid increase in absorbance with the number of 20 dippings. For Bi₂S₃ it appears that this effect is stronger if the triazole is contained in the Sulphide-solution, whereas for the PbS, it appears that this effect is stronger if the triazole is contained in the Metal solution. Furthermore, the triazole T2 appears to be more favourable for in-situ Bi₂S₃ nano-particle 25 formation than T1 and T3 and the triazole T3 appears to be more favourable for in-situ PbS formation than T1 and T2.

Table 1:

| Experi- | Metal | Metal | number of | triazole | triazole | Absorb- |
|-----------|----------|--------------------------------|-----------|----------|-------------|---------|
| ment nr. | solution | sulphide | dipping | compound | compound in | ance at |
| 1 | used | formed | cycles | in metal | sulphide | 500 nm* |
| | | | | solution | solution | |
| 1 (comp) | 1 | Bi ₂ S ₃ | 1 | No | No | 0.14 |
| 2 (comp) | 1 | Bi ₂ S ₃ | 2 | No | No | 1.28 |
| 3 (comp) | 1 | Bi ₂ S ₃ | 3 | No | No | 2.40 |
| 4 (comp) | 1 | Bi ₂ S ₃ | 5 | No | No | > 4 |
| 5 (inv) | 1 | Bi ₂ S ₃ | 11 | T1_ | No | 0.12 |
| 6 (inv) | 1 | Bi ₂ S ₃ | 1 | No | T1 | 0.23 |
| 7 (inv) | 11 | Bi ₂ S ₃ | 1 | Т2 | No | 0.18 |
| 8 (inv) | 1 | Bi ₂ S ₃ | 1 | No | Т2 | 0.51 |
| 9 (inv) | 1 | Bi ₂ S ₃ | 1 | т3 | No | 0.10 |
| 10 (inv) | 1 | Bi_2S_3 | 11 | No | Т3 | 0.33 |
| 11 (inv) | 1 | Bi ₂ S ₃ | 3 | T1 | No | > 4 |
| 12 (inv) | 1. | Bi ₂ S ₃ | 3 | No | T1 | > 4 |
| 13 (comp) | 2 | PbS | 1 | No | No | 0.12 |
| 14 (comp) | 2 | PbS | 2 | No | No | 0.37 |
| 15 (comp) | 2 | PbS | 3 | No | No | 0.59 |
| 16 (comp) | 2 | PbS | 5 | No | No | 1.23 |
| 17 (comp) | 2 | PbS | 7 | No_ | No | 2.47 |
| 18 (inv) | 2 | PbS | 11 | T1 | No | 0.24 |
| 19 (inv) | 2 | PbS | 1 | No | Т1 | 0.10 |
| 20 (inv) | 2 . | , Pp2 | | Т2 | No No | 0.18 |
| 21 (inv) | 2 | PbS | 1 | No | Т2 | 0.17 |
| 22 (inv) | 2 | PbS | 1 | Т3 | No | 0.32 |
| 23 (inv) | 2 | PbS | 1 | No | Т3 | 0.19 |
| 24 (inv) | 2 | PbS | 2 | Т1 | No | 0.61 |
| 25 (inv) | 2 | PbS | 3 | T1 | No | 1.30 |
| 26 (inv) | 2 | PbS | 3 | No | T1 | 0.63 |

^{*} corrected for the absorbance of TiO_2 at 500 nm (ca 0.15)

5 EXAMPLE 2

Evaluation in photovoltaic devices with liquid electrolyte

Photovoltaic devices 1 to 5 were prepared by the following

10 procedure:

Preparation of the front electrode

A glass plate $(2 \times 7 \text{ cm}^2)$ coated with conductive SnO_2 :F (Pilkington TEC15/3) with a surface conductivity of ca 15 5 Ohm/square was ultrasonically cleaned in isopropanol for 5 minutes and then dried.

For these experiments Degussa P25 TiO₂ nano-colloid was used instead of the Solaronix colloid, 5 g of Degussa P25 being added to 15 mL of water with 1 mL of Triton X-100 being subsequently added.

10 The resulting titanium dioxide colloidal dispersion was cooled in ice and ultrasonically treated for 5 minutes.

The electrode was taped off at the borders and was doctor blade-coated in the middle (0.7 x 4.5 cm²) with the above-described titanium dioxide colloidal dispersion to give layer thicknesses after sintering of 2.0 µm to ensure comparable optical absorbances of the cells. The sintering procedure and dipping procedure were as described for EXAMPLE 1. The front electrode was thereby produced, which was immediately used in assembling the cell.

20 Cell assembly

The back electrode (consisting of SnO2:F glass (Pilkington TEC15/3) evaporated with platinum to catalyse the reduction of the electrolyte) was sealed together with the front electrode with inbetween two pre-patterned layers of Surlyn®(DuPont) (2 x 7 cm² where in the middle 1 x 6 cm² had been removed). This was performed at a temperature just above 100°C on a hotplate. As soon as the sealing was completed, the cell was cooled to 25°C and electrolyte was added through holes in the counter electrode. The electrolyte used was a solution of 0.5 M LiI, 0.05 M I2 and 0.4 M thutylpyridine in acetonitrile and was injected into the cell during cell assembly. The holes were then sealed with Surlyn® and a thin piece of glass. Conductive tape was attached on both long sides of the cell to collect the electricity during measurement.

Measurements were performed immediately after the cell assembly.

Device characterisation

40 The thereby prepared photovoltaic cells were irradiated with a Xenon Arc Discharge lamp with a power of 100 mW/cm². The current generated was recorded with a Keithley electrometer (Type 2420).

The open circuit voltage (V_{oc}), short circuit current density (I_{sc}) and Fill Factor (FF) of the photocell as calculated from the quality of generated current are given in Table 3.

5 Table 3:

| Device | Metal | number | triazole | triazole | I _{sc} | Voc | FF |
|---------|----------|---------|----------|-------------|-----------------------|-------|------|
| nr | sulphide | of | compound | compound in | (mA/cm ²) | (V) | |
| | | dipping | in Metal | Sulphide | | | |
| | | cycles | solution | solution | | | |
| 1(comp) | PbS | 1 | No | No | 0.35 | 0.540 | 0.37 |
| 2(comp) | PbS | 2 _ | No | No | 0.44 | 0.463 | 0.42 |
| 3(comp) | PbS | 3 | No | No. | 0.64 | 0.460 | 0.31 |
| 4(inv) | PbS | 1 | T1 | No | 0.68 | 0.580 | 0.55 |
| 5(inv) | PbS | 2 | Т1 | No | 0.46 | 0.560 | 0.42 |

The absorbance values for the adsorbed in-situ formed lead sulphide nano-particles were not determined. However, the values reported 10 above for Experiments 5, 10, 11, 14 and 16 (see Table 1) for lead-sulphide nano-particles adsorbed on Solaronix titanium dioxide under the same conditions can be used as a guide.

From Table 3 it can be concluded that cells made with one dipping cycle with the triazole compound T1 show much better photoresponses than cells with one, two or even three dipping cycles in the absence of the triazole compound T1.

The present invention may include any feature or combination of features disclosed herein either implicitly or explicitly or any generalisation thereof irrespective of whether it relates to the presently claimed invention. In view of the foregoing description it will be evident to a person skilled in the art that various modifications may be made within the scope of the invention.

ABSTRACT

NANO-POROUS METAL OXIDE SEMICONDUCTOR SPECTRALLY SENSITIZED WITH METAL CHALCOGENIDE NANO-PARTICLES

A nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV in-situ spectrally sensitized on its internal and external surface with metal chalcogenide nano-particles with a band-gap of less than 2.9 eV containing at least one metal 10 chalcogenide, characterized in that said nano-porous metal oxide further contains a triazole or diazole compound; and a process for in-situ spectral sensitization of nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV on its internal and external surface with metal chalcogenide nano-15 particles with a band-gap of less than 2.9 eV, containing at least one metal chalcogenide, comprising a metal chalcogenide-forming cycle comprising the steps of: contacting the nano-porous metal oxide with a solution of metal ions; and contacting the nano-porous metal oxide with a solution of chalcogenide ions, wherein said 20 solution of metal ions and/or said solution of chalcogenide ions contains a triazole or diazole compound.

. The state of the

•

•

CLAIMS

1. A nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV in-situ spectrally sensitized on its internal and external surface with metal chalcogenide nanoparticles with a band-gap of less than 2.9 eV containing at least one metal chalcogenide, characterized in that said nanoporous metal oxide further contains a triazole or diazole compound.

10

5

 Nano-porous metal oxide according to claim 1, wherein said metal oxide is selected from the group consisting of titanium oxides, tin oxides, niobium oxides, tantalum oxides and zinc oxides.

15

- 3. Nano-porous metal oxide in-situ spectrally sensitized with metal chalcogenide nano-particles according to claim 1 or 2, wherein said triazole compound is a tetraazaindene.
- 20 4. Nano-porous metal oxide in-situ spectrally sensitized with metal chalcogenide nano-particles according to claim 3, wherein said tetraazaindene is selected from the group consisting of

25

Nano-porous metal oxide according to any of the preceding claims, wherein said nano-porous metal oxide further contains a phosphoric acid or a phosphate.

30

6. A process for in-situ spectral sensitization of nano-porous metal oxide semiconductor with a band-gap of greater than 2.9 eV on its internal and external surface with metal chalcogenide

nano-particles with a band-gap of less than 2.9 eV, containing at least one metal chalcogenide, comprising a metal chalcogenide-forming cycle comprising the steps of: contacting the nano-porous metal oxide with a solution of metal ions; and contacting the nano-porous metal oxide with a solution of chalcogenide ions, wherein said solution of metal ions and/or said solution of chalcogenide ions contains a triazole or diazole compound.

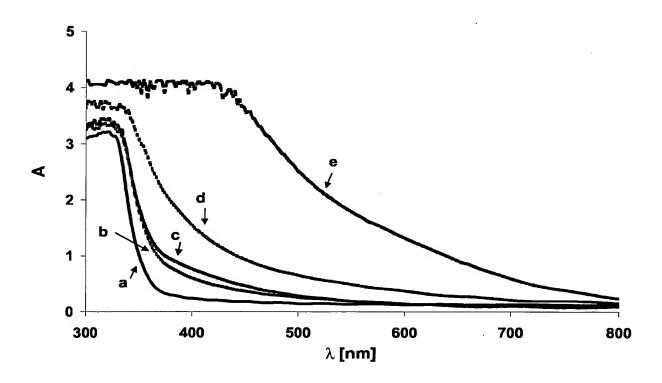
- 7. Process according to claim 6, wherein said contact with a solution of metal ions occurs before said contact with a solution of chalcogenide ions.
- 8. Process according to claim 6 or 7, wherein said metal chalcogenide is repeated.
 - 9. Process according to any of claims 6 to 8, wherein said triazole or diazole compound is tetraazaindene is selected from the group consisting of

20

$$\begin{array}{c|c} & OH \\ & N \\ & N \\ & OH \\ & N \\ & N \\ & OH \\ & OH$$

- 10. Process according to any of claims 6 to 9, wherein at the end of said metal chalcogenide-forming cycle said metal chalcogenide is rinsed with an aqueous solution containing a phosphoric acid or a phosphate.
- 11. A photovoltaic device comprising a nano-porous metal oxide in30 situ spectrally sensitized on its internal and external
 surface with metal chalcogenide nano-particles layer
 configuration according to any of claims 1 to 5 or prepared
 according to any of claims 6 to 10.

Figure 1:



| | | | T. Comment |
|---|---|--|------------|
| | | | |
| | | | |
| | | | 4 |
| | | | |
| | | | |
| | | | |
| | | |) V |
| | | | |
| | | | |
| | ř | | |
| | | | |
| , | | | |
| | | | |
| | | | |